Search Notes

Application/Control No.	Applicant(s)/Patent under Reexamination	
10/533,223	NISHIMURA ET AL.	
Examiner	Art Unit	
Rosemary E. Ashton	1752	

SEARCHED					
Class	Subclass	Date	Examiner		
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INTERFERENCE SEARCHED					
Class	Subclass	Date	Examiner		
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SEARCH NOTES (INCLUDING SEARCH STRATEGY)				
	DATE	EXMR		
CA STRUC.SEARCH FORM.(I - 1), N=0	1/21/2007	REA		
USPAT, USPGPUB,EPO,JPO, DERWENT, IBMTD: NORBORNYL ACRYLATE OR METHACRYLATE AND PHOTORESIST OR RESIST COMPOSITION OR RADIATION	1/21/2000	REA		
SENSITIVE				
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